



MAR 18 2004

UNITED STATES PATENT AND TRADEMARK OFFICE
(Case No. 211.001-D3-US)

In the Application of: **Fazan et al.**

) Group Art Unit:

Serial No: **10/724,648**

) Before Examiner

Filed: **December 1, 2003**

)

Title: **Semiconductor Device**

)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

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Date

Neil A. Steinberg
(person signing this certificate)

Neil A. Steinberg
Signature

FIRST INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Submitted herewith are twenty-three (23) sheets of a modified Form PTO-1449.

The documents listed on the modified Form PTO-1449 were provided or cited during the prosecution of parent applications of the above-captioned application are not enclosed herewith. (See 37 C.F.R. §1.98(d) and MPEP 609). Should the Examiner desire an additional copy of the documents previously provided or cited during the prosecution of parent applications, kindly contact the undersigned.

It is respectfully requested that the Examiner make his/her consideration of these references formally of record with the initial Office Action.

Respectfully submitted,

Neil A. Steinberg
Reg. No. 34,735
650-968-8079

Date: March 15, 2004



PTO-1449 (Mod. 01-01-01) U. S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE INFORMATION DISCLOSURE STATEMENT BY APPLICANT	ATTY. DOCKET NO. 211.001-D3-US	SERIAL NUMBER 10/724,648
	APPLICANT(S) Fazan et al.	
	FILING DATE December 1, 2003	GROUP ART UNIT

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	"The Multistable Charge-Controlled Memory Effect in SOI MOS Transistors at Low Temperatures", Tack et al., IEEE Transactions on Electron Devices, Vol. 37, No. 5, May 1990, pp.1373-1382

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	EP 0 801 427	10/1997	European			
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	"A Capacitorless Double-Gate DRAM Cell", Kuo et al., IEEE Electron Device Letters, Vol. 23, No. 6, June 2002, pp.345-347
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	"The Multi-Stable Behaviour of SOI-NMOS Transistors at Low Temperatures", Tack et al., Proc. 1988 SOS/SOI Technology Workshop (Sea Palms Resort, St. Simons Island, GA, Oct. 1988), p.78
	"The Multistable Charge-Controlled Memory Effect in SOI MOS Transistors at Low Temperatures", Tack et al., IEEE Transactions on Electron Devices, Vol. 37, No. 5, May 1990, pp.1373-1382
	"Mechanisms of Charge Modulation in the Floating Body of Triple-Well nMOSFET Capacitor-less DRAMs", Villaret et al., Proceedings of the INFOS 2003, Insulating Films on Semiconductors, 13th Bi-annual Conference, June 18-20, 2003, Barcelona (Spain), (4 pages)

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